

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	122	immersion adj (liquid apparatus lithography medium) and @ad<"20040122" and "355"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/27 14:50
S4	1	tbutoxyl adj acrylate	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/26 10:58
S5	288	polymer and immersion adj lithography	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/26 11:02
S6	2	silicon adj polymer and immersion adj lithography	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/26 11:08
S7	59	polymer with immersion adj lithography	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/26 13:17
S11	56	polymer with immersion adj (liquid apparatus lithography) and @ad<"20040122"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/26 13:44
S13	4	polymer same immersion adj (liquid apparatus lithography medium) and @ad<"20040122" and "355"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/27 09:41